

# 非对称超结场效应晶体管设计和仿真

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**摘要:** 为了克服传统功率 MOSFET 通态电阻和击穿电压之间的矛盾, 引入了超级结 (SJ) 器件, 通过引入横向电场来提高击穿电压. 针对工艺中非对称 pillar 的设计需求, 建立了非对称的研究分析模型, 通过引入影响设计的非对称因子  $k$ , 分析了  $k$  的物理意义和修正了不同 pillar 比例下的  $k$  值来设计相关参数, 推导出超结的设计解析表达式. 为了验证设计的准确性, 以沟槽栅 SJ-MOSFET 为器件, 进行了仿真验证和比较, 理论与仿真结果符合良好, 可以用于超结 MOSFET 的设计指导.

**关键词:** SJ-MOSFET; 非对称; 漂移区; 横向电场

## Design and Simulation of Asymmetric SJ-MOSFET

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**Abstract:** In order to overcome the traditional power MOSFET contradiction between on-state resistance and breakdown voltage, the super junction (SJ) device is introduced, so that it improves the breakdown voltage through the transverse electric field. In asymmetric pillar design requirements, establishing the asymmetry analysis model, introducing asymmetric factor  $k$ , analyzing the physical meaning of  $k$  and modifying the  $k$  value for pillar in different proportions, analytical expression of super junction is derived. In order to verify the accuracy of the design, basing on trench gate SJ-MOS device, simulation verification and comparison are carried out., theoretical and simulation results are in good agreement, the theory can be used as a guide for the design of super junction MOSFET.

**Key words:** SJ-MOSFET; asymmetric; drift region; transverse electric field

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